

LETTERS TO THE EDITOR

NOVEL REACTIONS TO FORM AN Si–O–Ge GROUP

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In study of O-silylation of hydroxyl-containing compounds [1-3] and hydrosilylation of the carbonyl group [3-6] in the presence of tris(pentafluorophenyl)borane [7], further reduction of the initially formed alkoxyasilanes by excess hydrosilane has been observed:



This reaction was suggested for preparative reduction of the carbonyl group to a methylene [8] or methyl [3, 8, 9] group without preliminary separation of the intermediate alkoxyasilanes.

Another group of researchers who were interested in organosilicon reaction products (1) suggested using it for synthesis of new siloxanes and polysiloxanes [10, 11].

In a study of the mechanism of the reaction of hydrosilanes with alkoxyasilanes in the presence of $\text{B}(\text{C}_6\text{F}_5)_3$, the following competing reaction was found involving exchange of substituents on the silicon atoms, with formation of a new hydrosilane and a new alkoxyasilane, which ultimately leads to formation of two symmetric and one nonsymmetric disiloxane [12].



Alkylhydrosilanes [1-3, 5, 6, 9, 10, 12], arylhydrosilanes [4-6], alkylarylhydrosilanes [6, 10-12], and hydrosiloxanes [8, 10] have been used in reactions (1) and (2).

We have shown that hetarylhydrosilanes, such as methyl(2-furyl)(2-thienyl)silane, also react with alkoxyasilanes in the presence of $\text{B}(\text{C}_6\text{F}_5)_3$. Its reaction with methyltriethoxysilane occurs with stepwise substitution of one and two ethoxy groups (Table 1, runs 6 and 7). With excess hydrosilane (run 8), we observe formation of 1,3-di(2-furyl)-1,3-dimethyl-1,3-di(2-thienyl)disiloxane (*via* exchange according to reaction (2)).

Condensation of triethylsilane with 1-ethoxysilatrane (run 10), containing a five-coordinate silicon atom in the ring, occurred with significantly more difficulty.

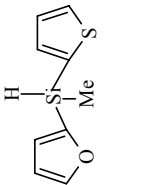
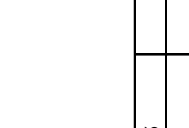
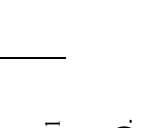
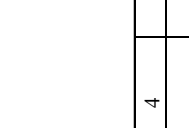

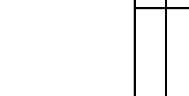
For the first time, we have established that alkoxygermanes (3) and hydrogermanes (4) enter into a similar reaction, with formation of an Si–O–Ge group.

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TABLE 1. Reaction of Hydrosilanes(germanes) with Alkoxysilanes(germanes)

Run	\geq M-OEt	\geq M-H	Hydrosilane equivalents	Reaction time, h	Major reaction products	% by GC/MS
1	2	3	4	5	6	7
1	Et ₃ SiOEt	Et ₃ SiH	1	1	Et ₃ SiOSiEt ₃	77
2	Et ₃ SiOEt	Et ₃ GeH	1	1	Et ₃ SiOGeEt ₃	66
3	MeSi(OEt) ₃	Et ₃ SiH	3	1	MeSiOEt(OSiEt ₃) ₂ MeSi(OSiEt ₃) ₃	30 40
4	MeSi(OEt) ₃	Et ₃ GeH	3	3	Et ₃ SiOSiEt ₃	10
5	MeSi(OEt) ₃	Et ₃ GeH	4	3	MeSi(OEt) ₂ OGeEt ₃	55
6	MeSi(OEt) ₃		1	1	MeSi(OEt) ₂ OGeEt ₃ MeSi(OEt) ₂ OGeEt ₃ OSi(OEt) ₂ Me	60 60
						10

TABLE 1 (continued)

1	2	3	4	5	6	7
7	MeSi(OEt) ₃		3	1		80
8	MeSi(OEt) ₃		4.5	1		85
9	 N(CH ₂ CH ₂ O) ₃ SiOEt	Et ₃ SiH	3	1		20
10	N(CH ₂ CH ₂ O) ₃ SiOEt	Et ₃ SiH	1	8	N(CH ₂ CH ₂ O) ₃ SiOSiEt ₃	Traces

* Reaction temperatures 50°C (runs 1-9) and 80°C (run 10).



In this case, hydrogermanes proved to be less reactive than hydrosilanes. Thus triethylgermane reacted with triethylethoxysilane more slowly than triethylsilane (runs 1 and 2), and only one ethoxy group was substituted in methyltriethoxysilane (runs 4 and 5) under conditions where triethylsilane substituted two and three ethoxy groups (run 3). Only one ethoxy group was substituted by the triethylsiloxy group in 2-thienyltriethoxygermane, when treated with triethylsilane (run 9).

The reactions were carried out in 8 ml toluene under a dry argon atmosphere with 1.4 mmol alkoxysilane and 0.07 mmol B(C₆F₅)₃; the products were analyzed by chromatography/mass spectrometry on an HP 6890 GC/MS spectrometer (70 eV) equipped with an HP-5 capillary column (30.0 m × 250 μm × 0.25 μm).

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